CLAIMS

[Claim 1]

An evaporation material for use in a vacuum deposition method, wherein the evaporation material comprises one or more types among Au, Ag, Pt, Pd and their alloys, micropores are formed on a surface of the evaporation material, and a number of the micropores having an equivalent circle diameter of 0.1 μm or more and 10.0 μm or less is one or more micropores per 500 μm^2, wherein the evaporation material has a cast structure.

[Claim 2]

The evaporation material according to claim 1, wherein a purity of the evaporation material is 3N (99.9 wt%) or higher.